## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Takaei SASAKI et al

Confirmation No.:

Serial No.: New Application

Filed: November 14, 2003

For: METHOD AND APPARATUS FOR DRY-ETCHING HALF-TONE

PHASE-SHIFT FILMS, HALF-TONE PHASE-SHIFT PHOTOMASKS

AND METHOD FOR THE PREPARATION THEREOF, AND SEMICONDUCTOR CIRCUITS AND METHOD FOR THE

**FABRICATION THEREOF** 

## **PRELIMINARY AMENDMENT**

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

November 14, 2003

Sir:

Prior to calculation of the filing fees and examination on the merits, please amend the above-identified application as follows: